## Electrical Properties of Evaporated Thin Films of Copper Phthalocyanine

Yoshiro Sakai, Yoshihiko Sadaoka, and Hirofumi Yokouchi

Department of Industrial Chemistry, Faculty of Engineering, Ehime University, Bunkyo-cho, Matsuyama, Ehime 790 (Received January 14, 1974)

The electrical properties of evaporated thin films of copper phthalocyanine (CuPc) were investigated by the ac method. The frequency dependence of conductivity and capacitance, and the activation energy for dc conductivity in  $\alpha$ - and  $\beta$ -CuPc were determined. No significant variation in the electrical properties was observed with the difference in the phases of CuPc films in vacuo. The frequency dependence of conductivity and capacitance can be explained in terms of the simultaneous hopping and band conduction, viz.,  $\sigma = \sigma_{\rm de} + A_1 \cdot \omega^n$  and  $C = C_{\infty} + A_2 \cdot \omega^{1-n}$ . The energy gap for  $\alpha$ - and  $\beta$ -CuPc in vacuo is 1.80 eV and 1.89 eV, respectively. The adsorbed  $O_2$  gas has a great effect on the dc conductivity but little on the ac conductivity of  $\alpha$ -CuPc film. The adsorption of oxygen on  $\alpha$ -phase CuPc might be the cause of high dc conductivity and low activation energy (0.5-0.7 eV) as compared with those in vacuo.

It is known that copper phthalocyanine(CuPc) can be obtained in two crystallographic modifications(α and  $\beta$ ). Wihksne and Newkirk<sup>1)</sup> found that the conductivity of form  $\alpha$  is greater than that of form  $\beta$  by a factor of 105, the activation energies being 0.25 eV and 0.9 eV, respectively. On the other hand, Harrison and Ludewig<sup>2)</sup> claimed that the difference in conductivity is due to the greater adsorptivity for oxygen on α-phase CuPc, and found that the conductivity of the  $\alpha$ -phase film is similar to that of the  $\beta$ -phase one when the oxygen has been eliminated. Eley and Parfitt<sup>3)</sup> studied the ac conductivity of aromatic compounds. They explained the frequency dependence of conductivity in a compressed powder disk in terms of contact resistance and contact capacitance(Maxwell-Wagner type dispersion). The frequency dependence of the conductivity in aromatic compounds can be explained in terms of the hopping conduction mechanism rather than the Maxwell-Wagner type dispersion.<sup>4,5)</sup> We have studied the frequency and temperature dependence of conductivity as well as the capacitance of  $\alpha$ - and  $\beta$ phase CuPc films.

## **Experimental**

Electrical measurements were carried out on evaporated thin  $\alpha$ - and  $\beta$ -phase CuPc films, the surface of the film being expected to be in alignment with its ab-plane. An ac bridge TR 10C(Ando Electrics Co., Ltd.) was used to measure the conductivity and capacitance. The sample was held in O2 or H<sub>2</sub> atmosphere or in vacuo (about 10-2 Torr). A sandwich type cell of thin film was prepared by evaporation on a microscope slide. The evaporation was carried out in a vacuum of the order of  $10^{-6}$  Torr, the rate of deposition of CuPc being approximately 10<sup>-7</sup> mm/s. The bottom electrode was an evaporated silver layer covered with an evaporated thin film of CuPc. The CuPc thickness was about 10<sup>-3</sup> mm. The top electrode was also prepared by the evaporation of silver. The cell constant was determined to be about  $2 \times 10^3$  cm. The  $\beta$ -phase CuPc was obtained by annealing the evaporated film at 320 °C for 30 min in N<sub>2</sub> atmosphere. 1,2) The transition from  $\alpha$  to  $\beta$ -phase on annealing was confirmed by the IR spectrum of the CuPc film which was deposited on a KBr disk. This was also confirmed by the change of electrical conductivity, the result being similar to that obtained by Wihksne and Newkirk<sup>1)</sup> as well as by Harrison and Ludewig.2) Measurements of the conductivity and the capacitance were carried out at temperatures 13-130 °C

( $\pm 2$  °C). The frequency was varied from 30 Hz to 1 MHz. The amplitude of the alternating voltage amounted to 20 V.

## Results and Discussion

Ebert and Gottlieb<sup>6</sup>) studied the X-ray diffraction and IR spectra of  $\alpha$ - and  $\beta$ -CuPc. Their results indicate that the IR spectrum of  $\alpha$ -CuPc differs from that of  $\beta$ -CuPc at the wavelengths 7.6, 9.2, 11.4, 13 and 14  $\mu$ m. The spectra of the deposited CuPc film on a KBr disk and the annealed one were found to be similar to those obtained by Ebert and Gottlieb, indicating that the evaporated film of CuPc on a slide glass is in the  $\alpha$ -phase while the annealed one is in the  $\beta$ -phase.<sup>2</sup>)

The frequency dependence of conductivity for the  $\alpha$ - and  $\beta$ -CuPc films in vacuo at various temperatures is shown in Figs. 1 and 2. The temperature and the frequency dependences of the electrical properties for both  $\alpha$ - and  $\beta$ -CuPc in vacuo were found to be similar, indicating that there is no significant difference between the two phases. In the high frequency region, it was found that the conductivity of both  $\alpha$ - and  $\beta$ -CuPc is proportional to  $\omega^n$ :

$$\sigma_{ac} = A_1 \cdot \omega^n \tag{1}$$

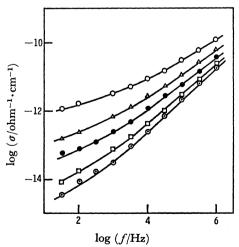


Fig. 1. Frequency dependence of conductivity of α-CuPc film in vacuo.

- (O) 124 °C, (△) 98 °C, (●) 74 °C, (□) 47 °C,
- (⊙) 27 °C.

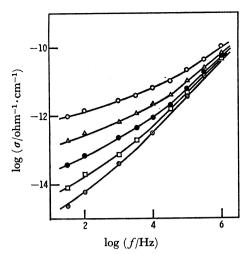


Fig. 2. Frequency dependence of conductivity of  $\beta$ -CuPc film *in vacuo*.

- (○) 127 °C, (△) 99 °C, (●) 76 °C, (□) 45 °C,
- (①) 18 °C.

where  $\omega$  is the angular frequency. The value of n decreases from 1.0 to 0.5 with an increase in temperature.  $\sigma_{ac}$  at low frequencies was calculated by extrapolation from the high frequency region on the assumption that  $\sigma_{ac}$  obeys Eq. (1) over the whole range of frequency. In the low frequency region the difference between  $\sigma_{ac}$  value thus obtained and the observed conductivity increases with an increase in temperature.

We have studied the frequency and temperature dependence of conductivity of aromatic compounds in both an evaporated thin film and a compressed powder disk and have found that the observed conductivity can be expressed as the sum of two terms, the band conduction and the hopping conduction.<sup>4,5)</sup> The latter strongly depends on frequency, but not the former. Thus we have

$$\sigma = \sigma_{ac} + \sigma_{dc}$$

$$= A \cdot \omega^n \cdot \exp[-E(T \cdot \omega)/kT] + \sigma_0 \cdot \exp(-E/kT) \qquad (2)$$

where  $\sigma_{ac}$  is the frequency dependent conductivity,  $\sigma_{de}$  is the frequency independent conductivity,  $E(T \cdot \omega)$ , the apparent activation energy for hopping from one localized state to another, is a function of both temperature<sup>7-9</sup>) and frequency, and E is the activation energy of the band conduction. When the conductivity is given by Eq. (2), the Kramers-Kronig relation<sup>10</sup>) can be used to determine the frequency dependence of the capacitance:

$$C = C_{\bullet} + A_2 \cdot \omega^{1-n} \tag{3}$$

The values of n for conductivity and capacitance were obtained at various temperatures by use of Eqs. (2) and (3). It was assumed that  $C_{\bullet}$  is roughly equal to the value of C at 1MHz. The values of n thus obtained are given in Table 1. The values of n in C are in fair agreement with those in  $\sigma_{ae}$ . The results indicate that the frequency dependence of conductivity and capacitance can be expressed by Eqs. (2) and (3) within experimental error. We see that  $\sigma_{ae}$  of  $\alpha$ -CuPc and that of  $\beta$ -CuPc do not differ greatly (Fig.

Table 1. Values of n for  $\alpha\text{-CuPc}$  and  $\beta\text{-CuPc}$  films  $in\ \textit{vacuo}$  and in  $H_2$  atmosphere

Phase	Temp.	$\frac{n}{\text{in } \sigma_{ac}}$	in C
β in vacuo	127 99 76 45	$egin{array}{c} 0.4_9 \ 0.5_4 \ 0.6_8 \ 0.8_3 \ \end{array}$	0.5 <sub>2</sub> 0.5 <sub>7</sub> 0.6 <sub>4</sub>
α in vacuo	124 98 74 47 27	$0.5_{0}$ $0.6_{3}$ $0.6_{9}$ $0.8_{1}$ $0.8_{3}$	$0.5_{7}$ $0.5_{9}$ $0.7_{5}$ $0.7_{6}$
$_{ m in}^{lpha}$	$ \begin{cases} 122 \\ 99 \\ 73 \\ 54 \\ 31 \end{cases} $	$0.5_{0} \\ 0.5_{5} \\ 0.6_{5} \\ 0.7_{2} \\ 0.8_{4}$	0.5 <sub>0</sub> 0.5 <sub>4</sub> 0.5 <sub>9</sub> 0.6 <sub>6</sub>

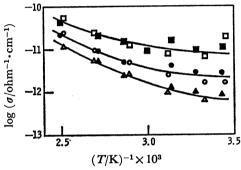


Fig. 3. Temperature dependence of conductivity in the high frequency region of  $\alpha$ - and  $\beta$ -CuPc films in vacuo.

$$(\square, \bigcirc, \triangle)$$
  $\alpha$ -CuPc,  $(\blacksquare, \bullet, \blacktriangle)$   $\beta$ -CuPc,  $(\square, \blacksquare)$  300 kHz,  $(\bigcirc, \bullet)$  100 kHz,  $(\triangle, \blacktriangle)$  30 kHz.

3). The apparent activation energy of ac conductivity decreases with the increase in frequency and the decrease in temperature for both  $\alpha$ - and  $\beta$ -CuPc in vacuo.

The temperature dependence of  $\sigma_{\rm de}$  (= $\sigma$ - $A_1 \cdot \omega^n$ ) was obtained for both  $\alpha$ - and  $\beta$ -CuPc (Fig. 4). The activation energy of  $\sigma_{\rm de}$  is 0.90 eV and 0.94 eV for the  $\alpha$ -CuPc and the  $\beta$ -CuPc film in vacuo, respectively. These are in fair agreement with those obtained by Harrison and Ludewig.<sup>2)</sup>

The effect of adsorbed O<sub>2</sub> gas on the electrical properties was investigated. The frequency dependence of conductivity for α-CuPc film in H<sub>2</sub> and O<sub>2</sub> is shown in Figs. 5 and 6. The frequency dependence of conductivity and capacitance in H2 is similar to that in vacuo (Table 1) but the activation energy of dc conductivity is slightly larger than that in vacuo. In the low frequency range, the conductivity of α-CuPc in O<sub>2</sub> is larger than that in vacuo by a factor of 104 at room temperature. The magnitude of  $\sigma_{dc}$  was poorly reproducible, being strongly affected by the condition of O2 gas adsorption. The activation energy was found to be 0.5-0.7 eV. When the contribution of  $\sigma_{dc}$  component is large, the frequency dependence of  $\sigma_{ac}$  can be obtained by subtracting  $\sigma_{de}$  from  $\sigma$  on the assumption that the value of  $\sigma_{de}$  is approximately equal to that of  $\sigma$  in the low

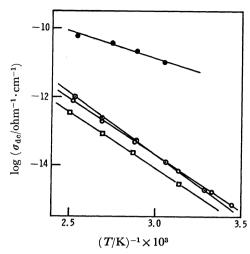


Fig. 4. Temperature dependence of dc conductivity of CuPc film in various conditions.

( ) β-CuPc film in vacuo, ( ) α-CuPc film in vacuo, (⊙) α-CuPc film in H<sub>2</sub> atmosphere, (●) α-CuPc film in O<sub>2</sub> atmosphere.

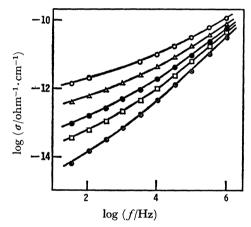


Fig. 5. Frequency dependence of conductivity of  $\alpha$ -CuPc film in  $H_2$  atmosphere.

- (○) 122 °C, (△) 99 °C, (●) 73 °C, (□) 54 °C,
- (①) 31 °C.

frequency region. The frequency dependence of  $\sigma_{ac}$ is shown in Fig. 7. It can thus be said that the  $\sigma_{ac}$ is little affected by the adsorbed O2.

The band conduction  $\sigma_{de}$  becomes gradually predominant at low frequency range with temperature rise, so that in the high temperature region the conductivity depends little on the frequency. Such a remarkable tendency is observed in particular in α-CuPc under O2 atmosphere. It seems that the hopping conduction  $\sigma_{ac}$  is mainly based on the localized state (and/ or shallow traps) which might be produced by crystal

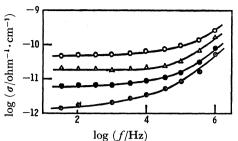


Fig. 6. Frequency dependence of conductivity of  $\alpha$ -CuPc in O2 atmosphere.

(○) 120 °C, (△) 74 °C, (●) 55 °C, (⊙) 34 °C.

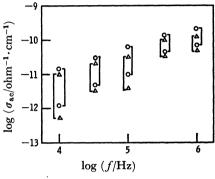


Fig. 7. Frequency dependence of  $\sigma_{ac}$  of  $\alpha$ -CuPc films.

- (O) in O2 introduced after evacuation,
- $(\triangle)$  in  $H_2$  atmosphere.

defects but not adsorbed oxygen, and the band conduction  $\sigma_{de}$  is due to electrons excited to the conduction band and/or holes to the valence band. Since the frequency at which traps produced by adsorbed oxygen are filled and emptied is greater than the applied field frequencies, the adsorbed oxygen has no effect on thermally and frequency assisted hopping conduction.

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